

7th IEEE Electron Devices Technology and Manufacturing (EDTM) Conference 2023

March 7 – 10, 2023 / COEX Seoul, Korea

52D. Group IV Devices	
Session Date:	March 10(Fri.), 2023
Session Time:	10:40-12:20
Session Room:	Room D (#308 bc)
Session Chair:	Prof. Woo Young Choi (Seoul National University)

[52D-1] [Invited] 10:40-11:05

Building the Path to Ubiquitous Wireless Connectivity, from Materials to Systems

Luis Andia and Yvan Morandini

Soitec

[52D-2] 11:05-11:20

Operation Scheme Optimization for Charge Trap Transistors (CTTs) Based on Fully Depleted Silicon-on-Insulator (FDSOI) Platform

Wannian Wang¹, Bing Chen¹, Jiayi Zhao¹, Sebastien Loubriat², Guillaume Besnard³, Christophe Maleville³, Olivier Weber⁴ and Ran Cheng¹

¹Zhejiang University, ²CEA-Leti, ³Soitec, ⁴STMicroelectronics

[52D-3] 11:20-11:35

Variable-Temperature Broadband Noise Characterization of MOSFETs for Cryogenic Electronics: from Room Temperature down to 3 K

Kenji Ohmori¹ and Shuhei Amakawa²

¹Device Lab Inc., ²Hiroshima University

[52D-4] 11:35-11:50

Improved Electrical Characteristics of Ge p-MOSFET with Ti-GeO_x Interfacial Layer by In-Situ Plasma-Enhanced Atomic Layer Deposition

Hui-Hsuan Li¹, Yu-Hsien Lin², Tsung-Yen Tu² and Chao-Hsin Chien¹

¹National Yang Ming Chiao Tung University, ²National United University

[52D-5] 11:50-12:05

SiGe-Based Nanowire HBT for THz Applications

Soumya Ranjan Panda^{1,2}, Sebastien Fregonese¹, Anjan Chakravorty² and Thomas Zimmer¹

¹University of Bordeaux, ²Indian Institute of Technology Madras

[52D-6] 12:05-12:20

1T FDSOI Based LIF Neuron without Reset Circuitry: A Proposal and Investigation

V Rajakumari¹, S R Panda² and K P Pradhan¹

¹Indian Institute of Information Technology, Design and Manufacturing Kancheepuram, ²University of Bordeaux